

Supporting Information

Iodine doped composite with biomass carbon dots and reduced graphene oxide: A versatile bifunctional electrode for energy storage and oxygen reduction reaction

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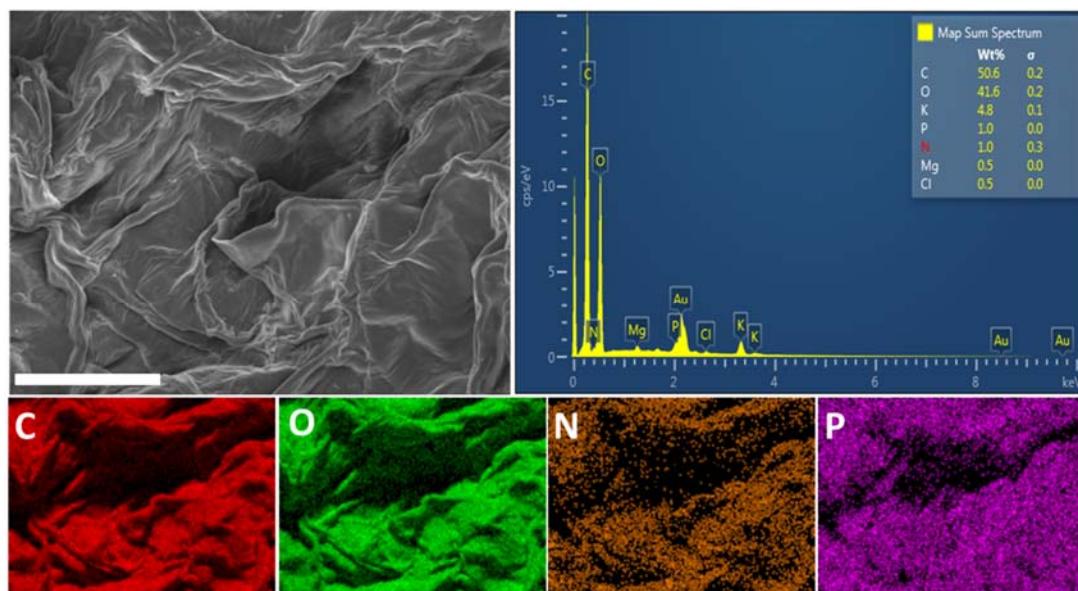


Fig S1. SEM image, EDX spectra and elemental mappings of eggplant used in this study. The scale bar is 50 μm .

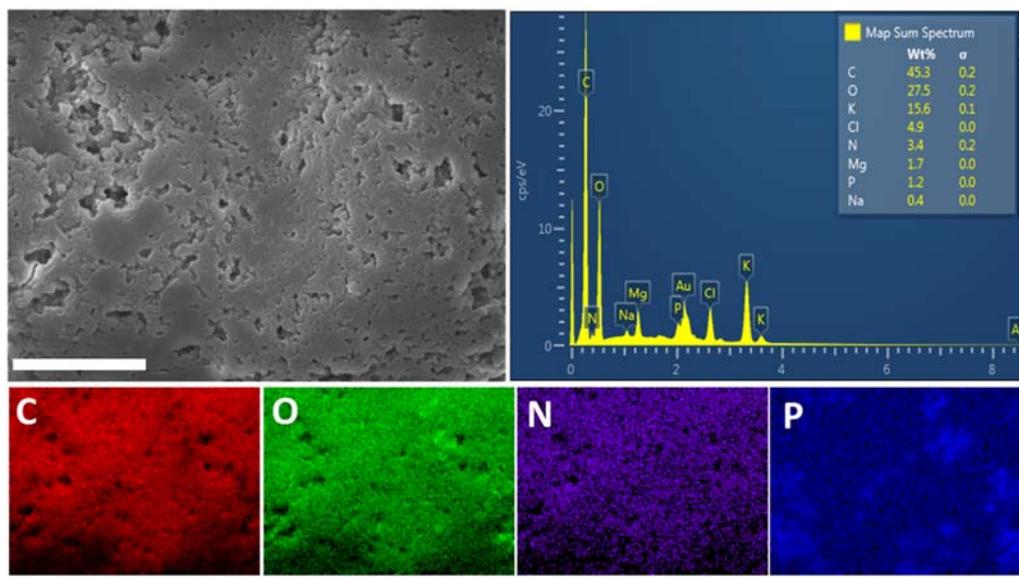


Fig S2. SEM micrograph, corresponding EDX spectrum and elemental mappings of the as-prepared CDs. The scale bar is 10 μm .

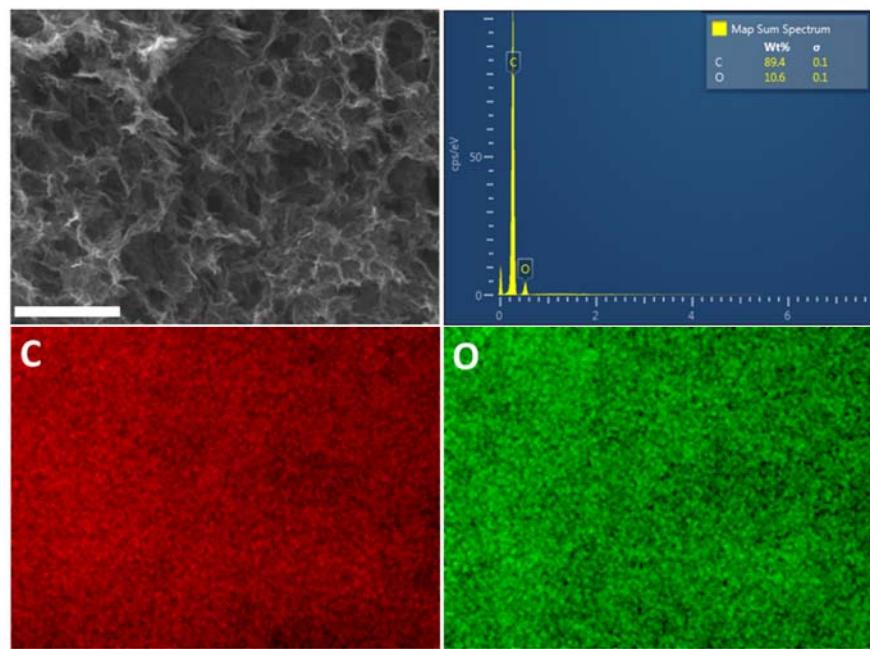


Fig S3. SEM image and corresponding EDX elemental mappings of RGO. The scale bar is 2.5 μm .

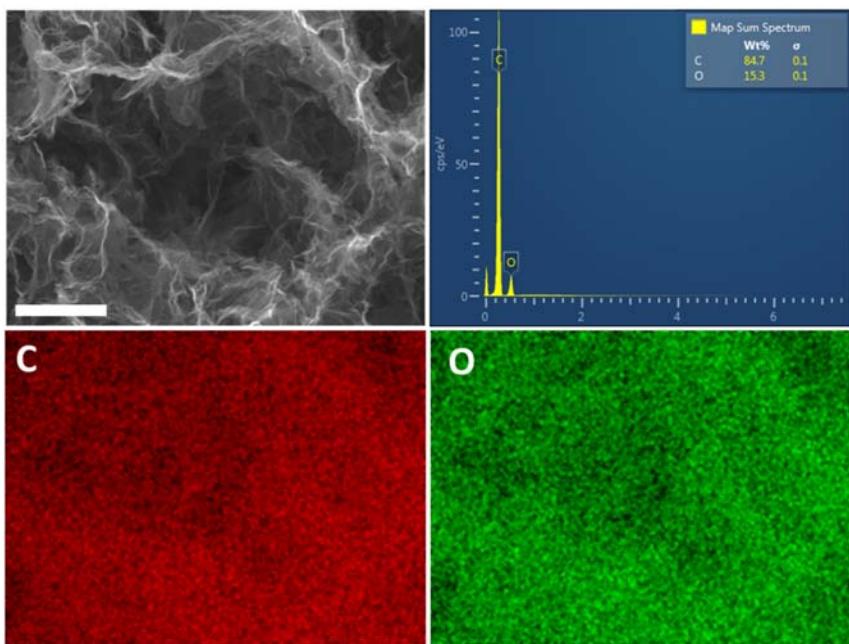


Fig S4. SEM image and corresponding EDX elemental mappings of the RGO/CDs composite. The scale bar is 2.5 μm .

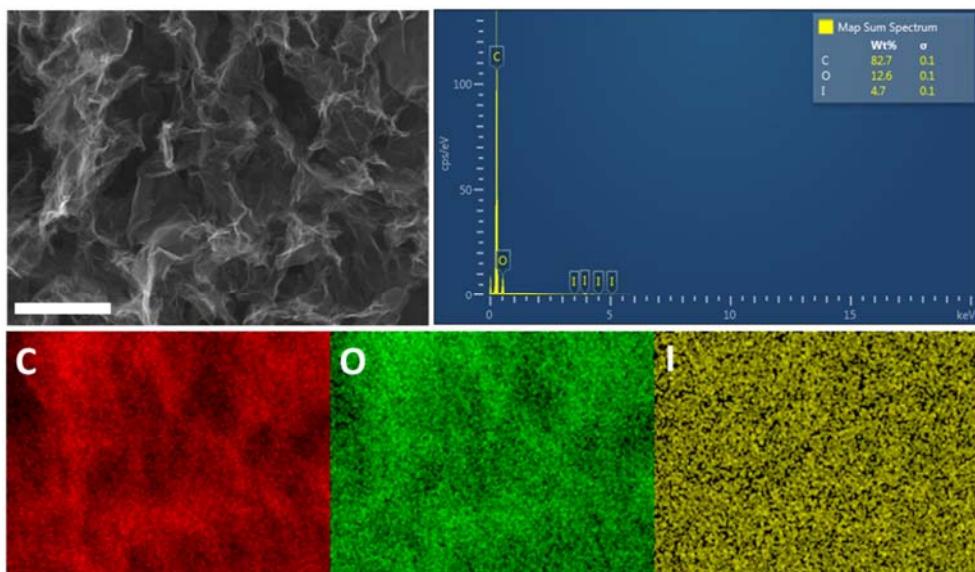


Fig S5. SEM image and corresponding EDX elemental mappings of the HI-RGO/CDs. The scale bar is 2.5 μm .

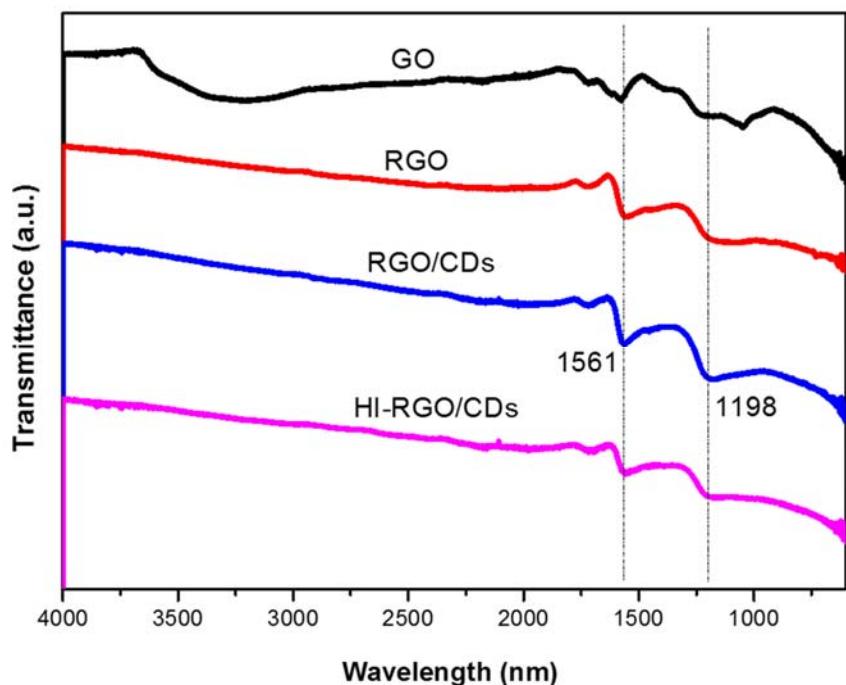


Fig S6. FTIR spectra of various samples.

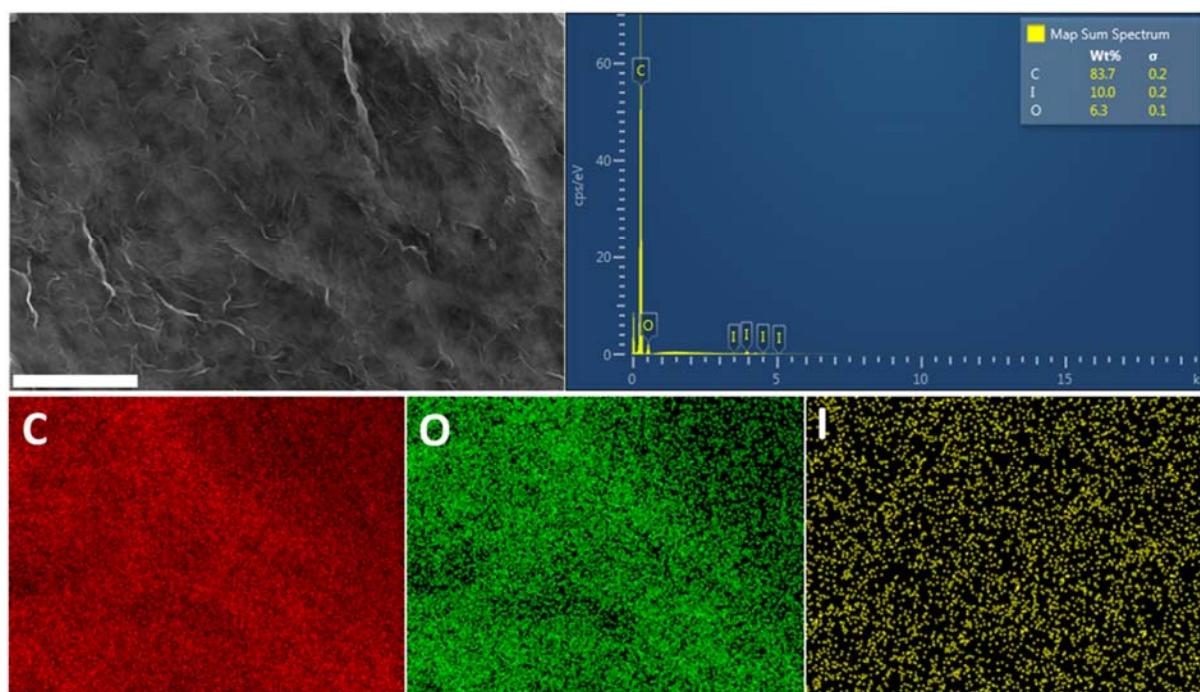


Fig S7. SEM image and corresponding EDX elemental mappings of the HI-RGO. The scale bar is 2.5 μ m.

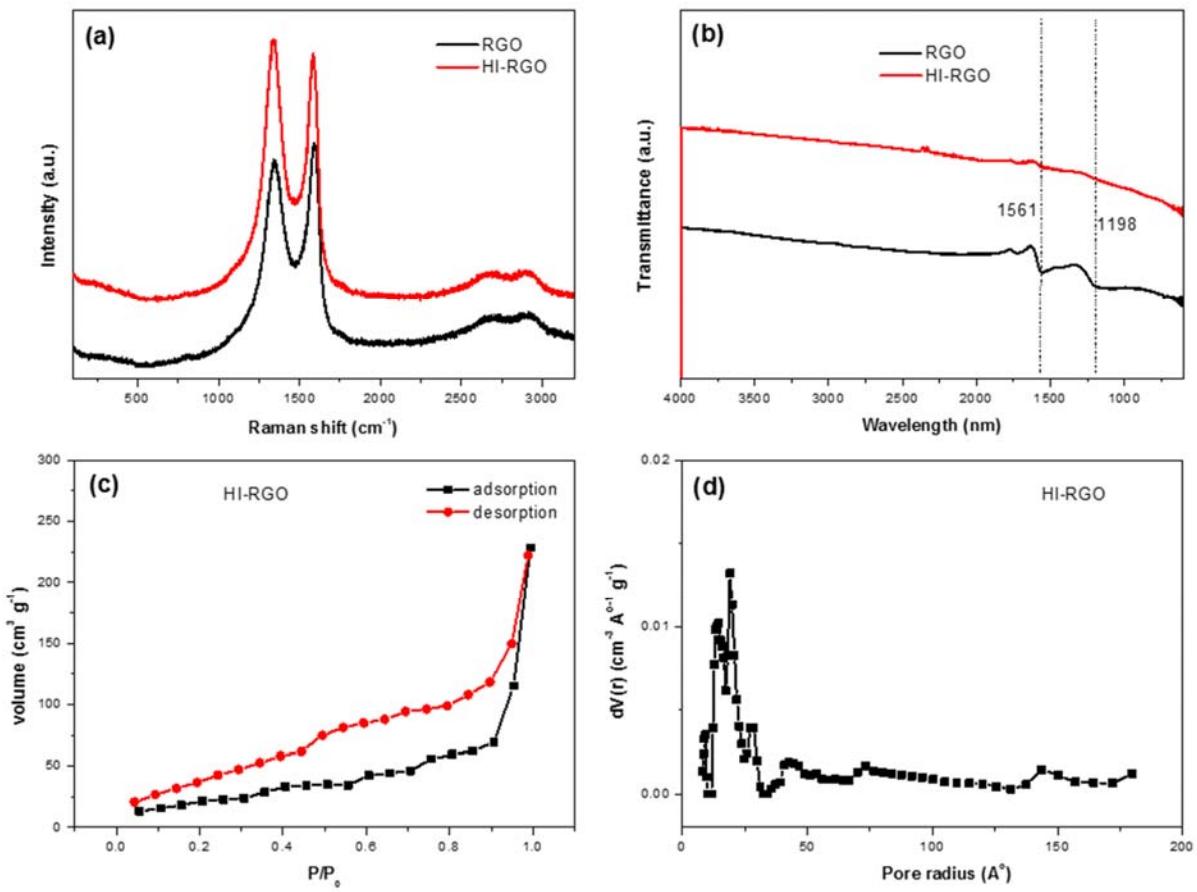


Fig S8. Comparison of Raman (a) and FTIR (b) spectra of RGO and HI-RGO, (c) nitrogen adsorption/desorption isotherms and (d) pore size distributions of HI-RGO.

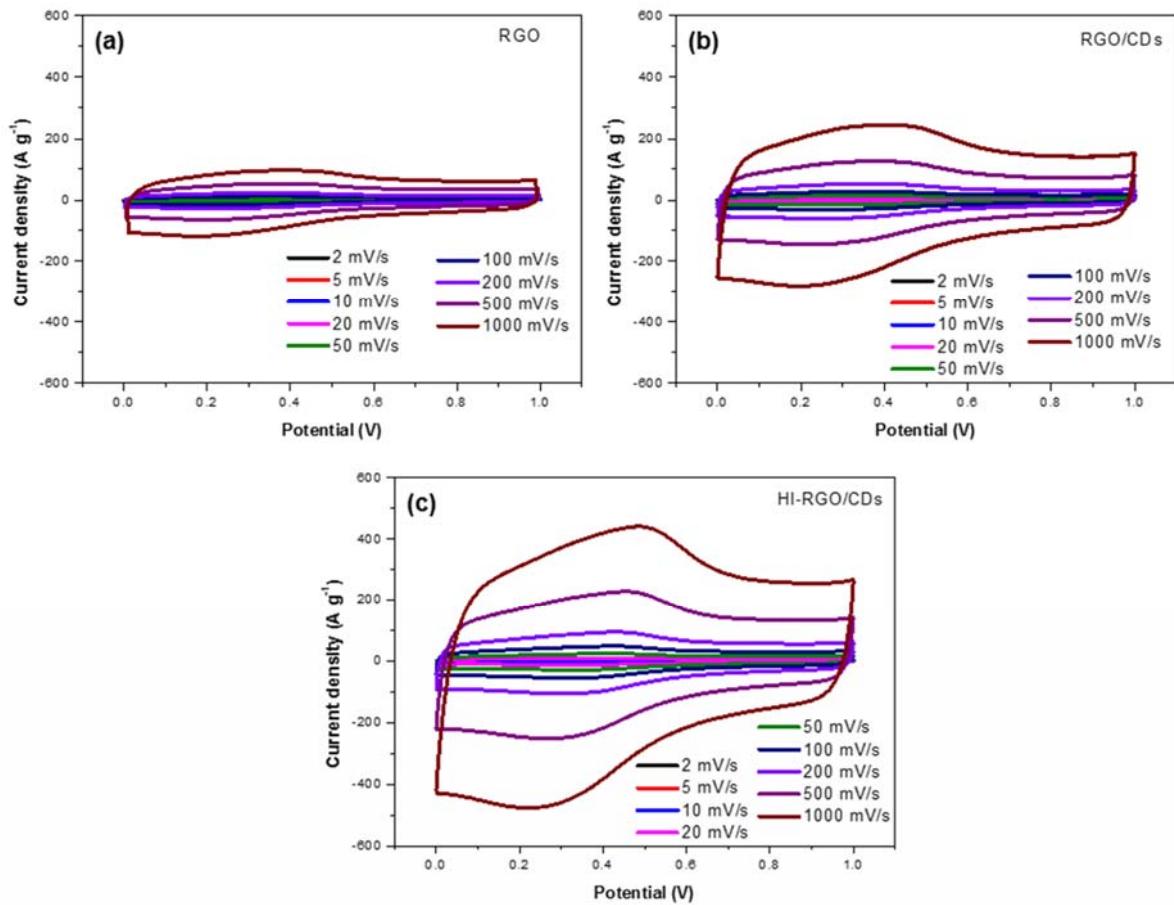


Fig S9. CV curves of (a) RGO, (b) RGO/CDs and (c) HI-RGO/CDs in 1 M H_2SO_4 .

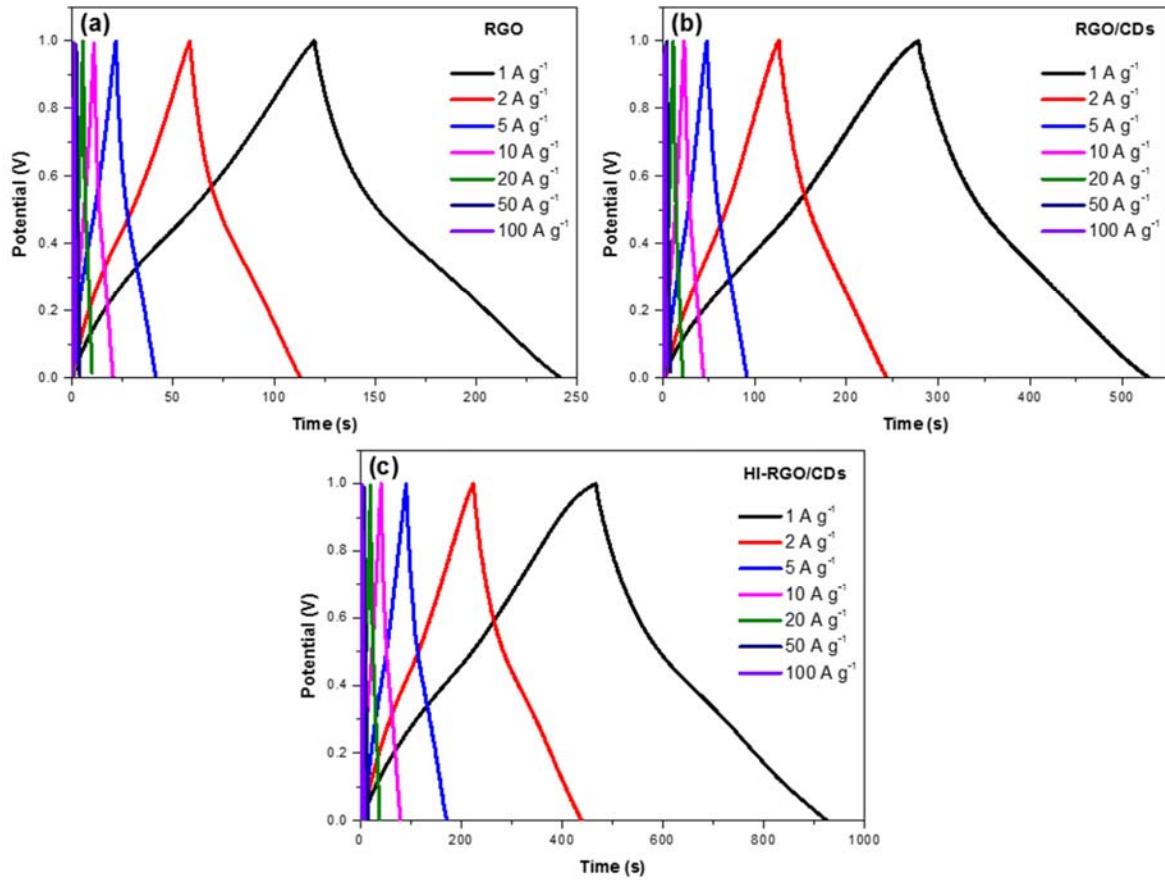


Fig S10. Galvanostatic charge/discharge curves of (a) RGO, (b) RGO/CDs and (c) HI-RGO/CDs in 1 M H₂SO₄.

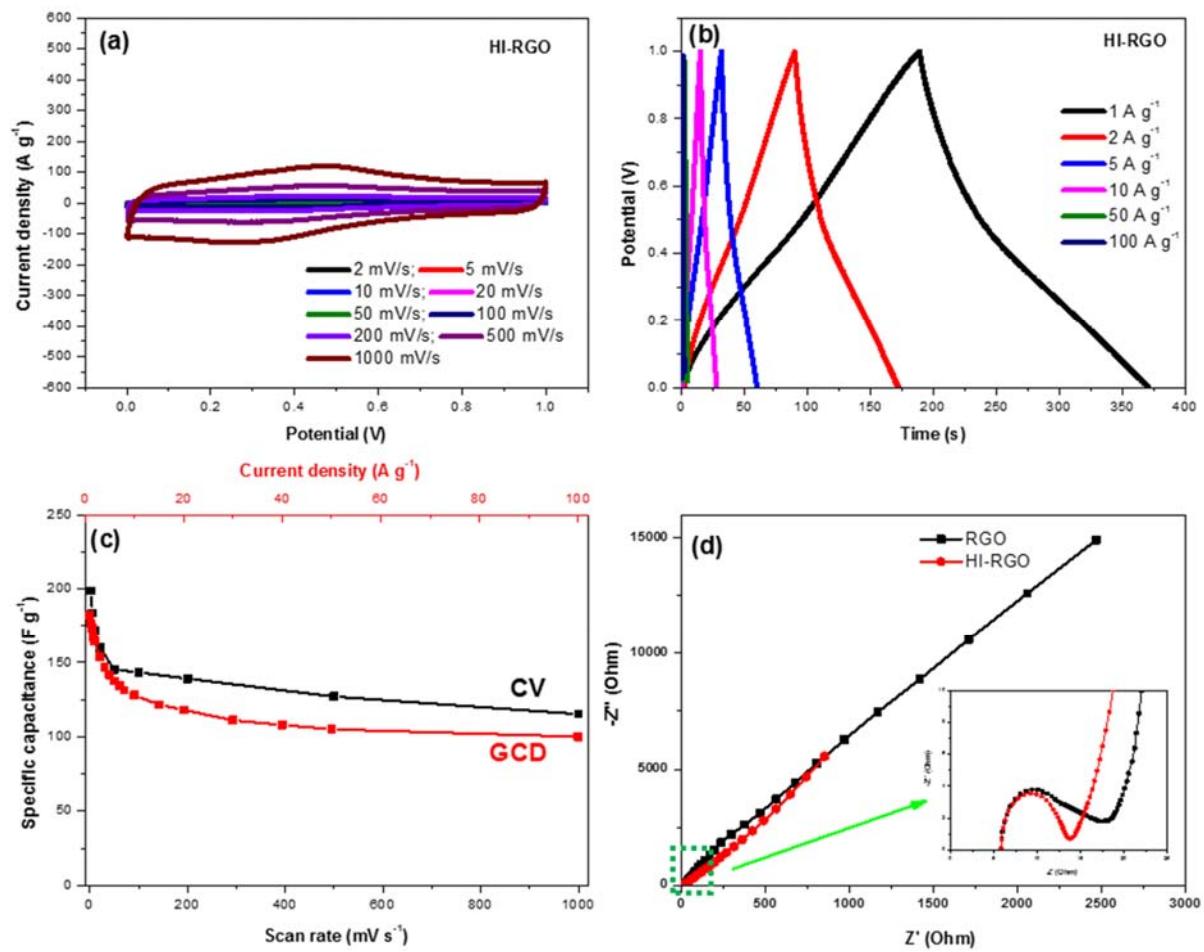


Fig S11. (a) CV curves, (b) GCD curves of HI-RGO in 1 M H₂SO₄, (c) specific capacitance of materials calculated from its CV and GCD curves, (d) comparison of Nyquist plots of RGO and HI-RGO.

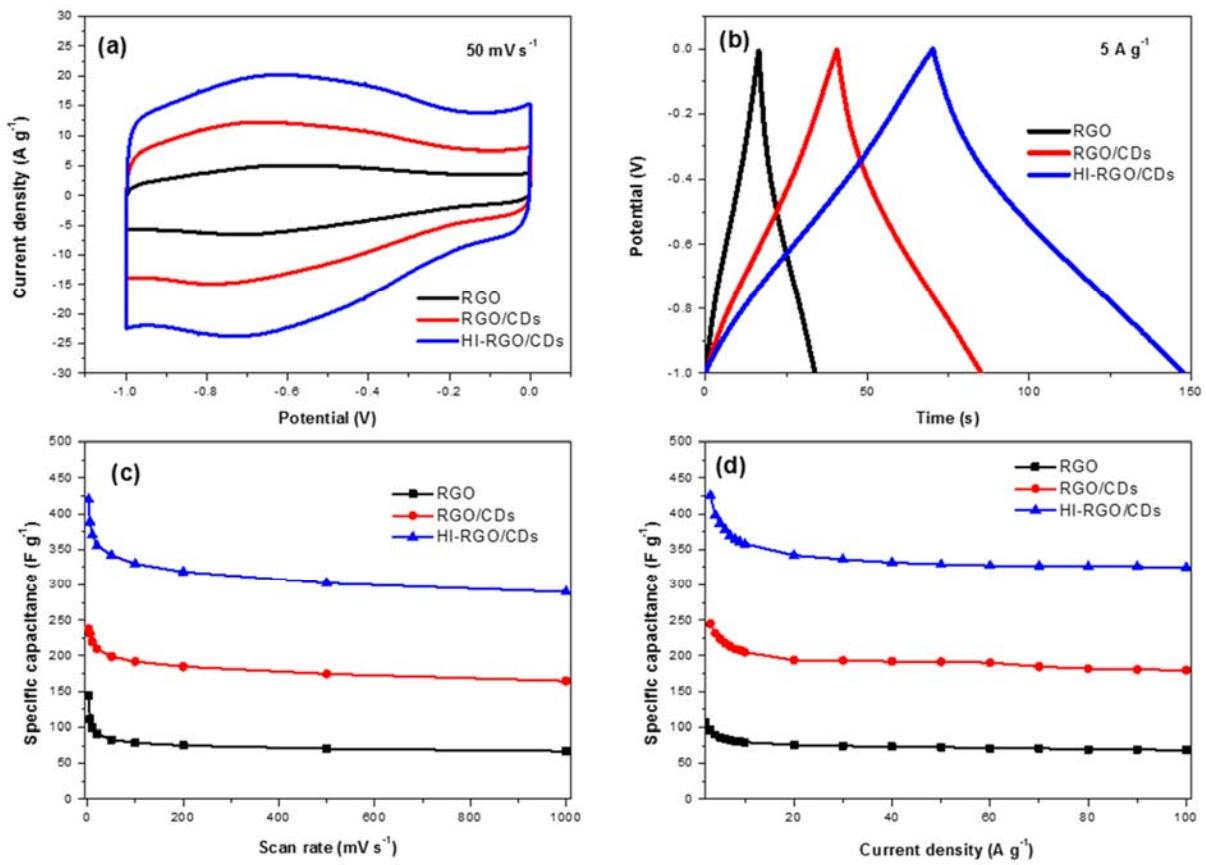


Fig S12. (a) CV curves at 50 mV s^{-1} in 1 M KOH ; (b) galvanostatic charge/discharge curves at 1 A g^{-1} of three samples in 1 M KOH ; (c) specific capacitances calculated from CV, (d) specific capacitances from GCD curves.

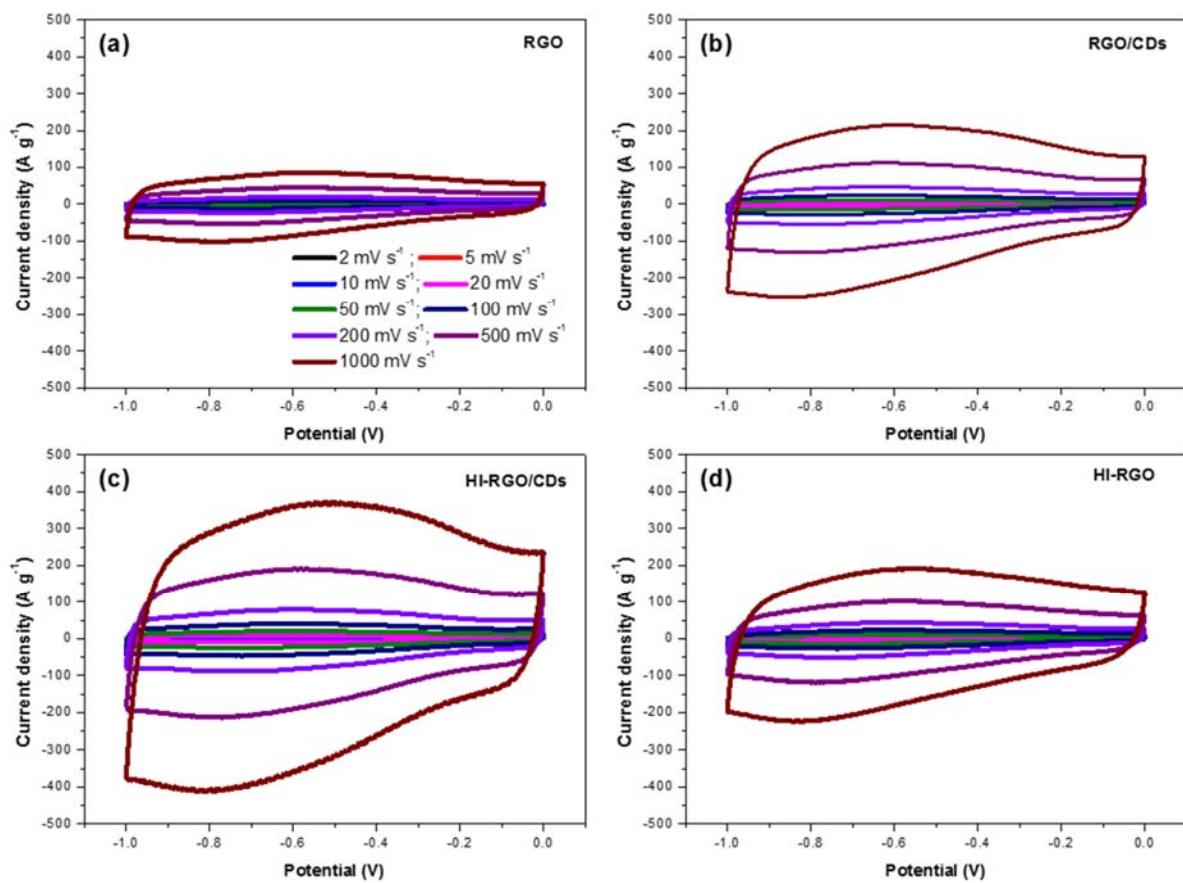


Fig S13. CV curves of (a) RGO, (b) RGO/CDs, (c) HI-RGO/CDs and (d) HI-RGO in 1 M KOH.

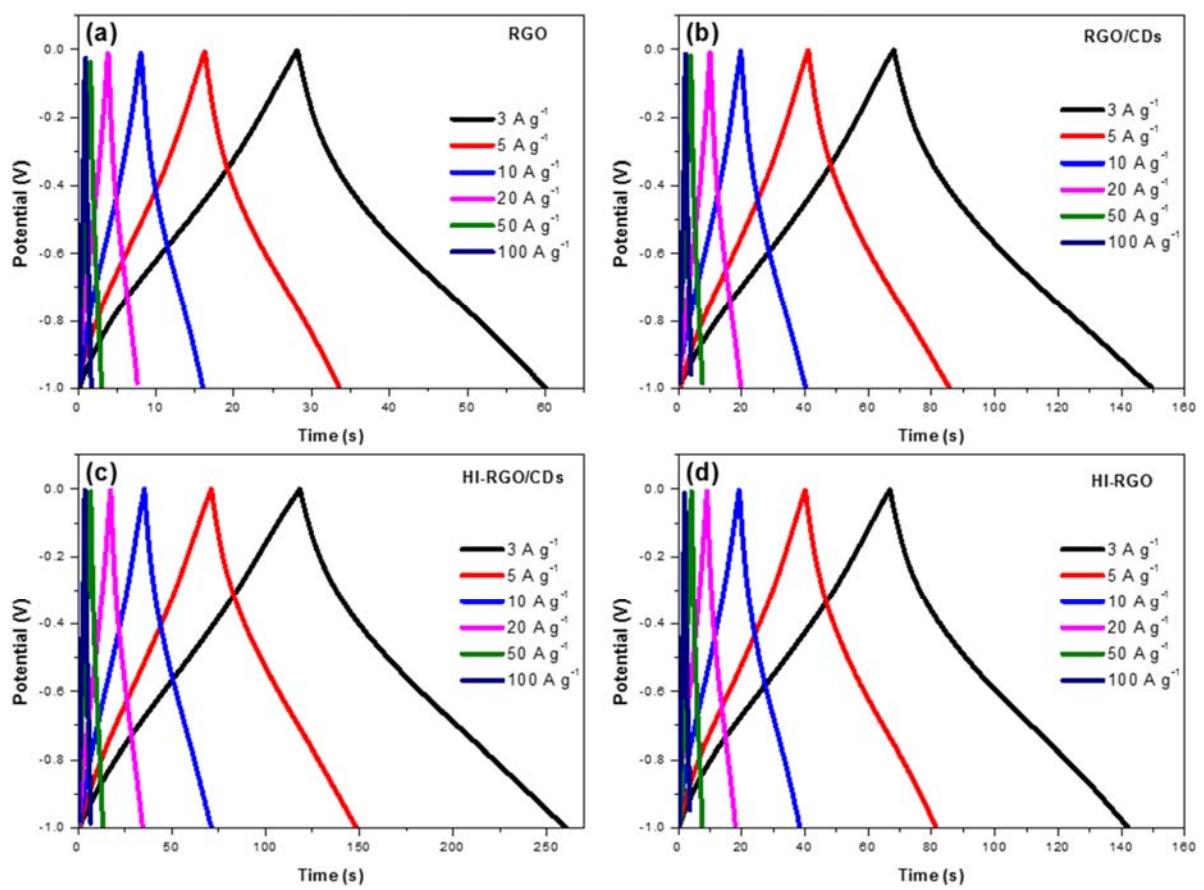


Fig S14. Galvanostatic charge/discharge curves of (a) RGO, (b) RGO/CDs, (c) HI-RGO/CDs and (d) HI-RGO in 1 M KOH.

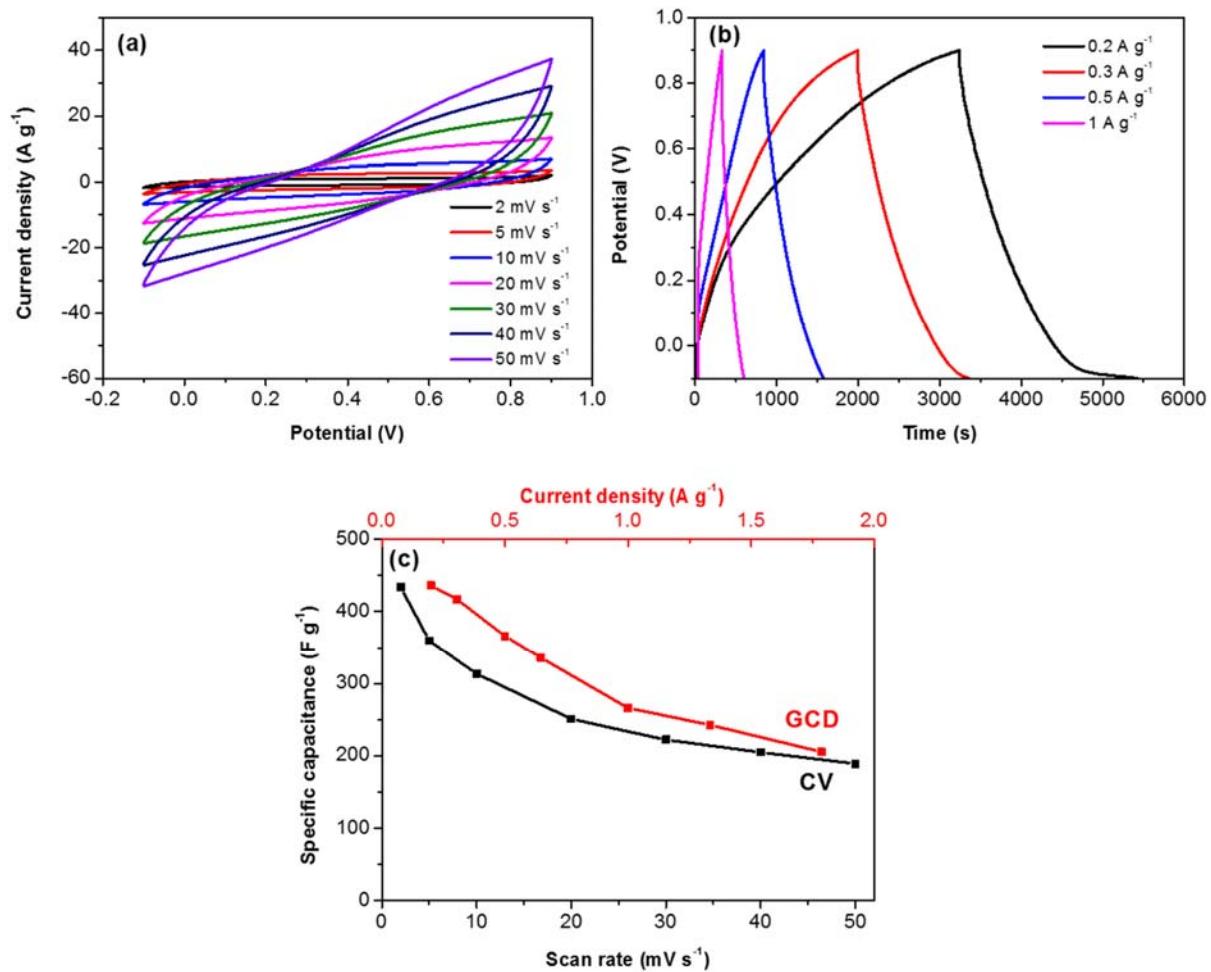


Fig S15. (a) CV curves, (b) GCD curves of HI-RGO/CDs at high loading of 8 mg cm^{-2} on Ni foam in $1 \text{ M Na}_2\text{SO}_4$, (c) specific capacitance of materials calculated from its CV and GCD curves.

Table S1. Comparison of graphene based supercapacitors reported in the literature.

References	Electrode materials	Max specific capacitance (F g^{-1})	Current density / scan rate	Electrolyte
This work	HI-RGO/CDs	432 295 460	2 mV s^{-1} $1,000 \text{ mV s}^{-1}$ 1 A g^{-1}	$1 \text{ M H}_2\text{SO}_4$

		352	100 A g^{-1}	
		420	2 mV s^{-1}	1 M KOH
		290	$1,000 \text{ mV s}^{-1}$	
		426	3 A g^{-1}	
		325	100 A g^{-1}	
¹	I-graphene/CDs	374	2 mV s^{-1}	1 M KOH
		352	5 mV s^{-1}	
²	CDs/graphene hydrogel	264	1 A g^{-1}	1 M H ₂ SO ₄ -PVA
		210	10 A g^{-1}	
³	N,S-codoped CDs/RGO	141	0.13 A g^{-1}	1 M Na ₂ SO ₄
⁴	RGO/CDs	262	2 A g^{-1}	6 M KOH
		247	5 A g^{-1}	
		236	10 A g^{-1}	
⁵	CDs/RGO	212	0.5 A g^{-1}	1 M H ₂ SO ₄
⁶	N-doped CDs/RGO	278	0.2 A g^{-1}	1 M H ₂ SO ₄
		227	2 mV s^{-1}	
⁷	Graphene hydrogel	175	10 mV s^{-1}	5 M KOH
⁸	N,B-codoped graphene	239	1 mV s^{-1}	1 M H ₂ SO ₄
⁹	Graphene/carbon aerogel	122	0.05 A g^{-1}	6 M KOH
¹⁰	N-doped graphene	282	0.2 A g^{-1}	6 M KOH
¹¹	Graphene/SWCNT	199	0.5 A g^{-1}	EMIM-BF ₄
¹²	Mesoporous carbon/graphene aerogel	226	1 mV s^{-1}	1 M H ₂ SO ₄
¹³	Nitrogen-Superdoped 3D Graphene	380	0.6 A g^{-1}	6 M KOH
		312	5 mV s^{-1}	

¹⁴	Hydroquinone functionalized graphene hydrogel	441 352	1 A g ⁻¹ 20 A g ⁻¹	1 M H ₂ SO ₄
¹⁵	Nitrogen-doped graphene hydrogels	308	3 A g ⁻¹	6 M KOH
¹⁶	Rumpled N-doped rGO sheets	479 423	1 A g ⁻¹ 5 mV s ⁻¹	1 M H ₂ SO ₄
¹⁷	Holey RGO framework	310	1 A g ⁻¹	6 M KOH
¹⁸	Three-dimensional Nitrogen-doped graphene	334	0.5 A g ⁻¹	6 M KOH
¹⁹	P-doped graphene	367	5 mV s ⁻¹	1 M H ₂ SO ₄
²⁰	Nitrogen-doped graphene hollow nanospheres	381	1 A g ⁻¹	6 M KOH
²¹	N doped graphene	326	0.2 A g ⁻¹	6 M KOH
²²	N-doped, ultralight graphene framework	484 417	1 A g ⁻¹ 100 A g ⁻¹	1 M LiClO ₄
²³	Nitrogen doped RGO	364.6	10 mV s ⁻¹	1 M H ₂ SO ₄
²⁴	Nitrogen doped RGO	459	1 mA cm ⁻²	1 M H ₂ SO ₄
²⁵	Nitrogen doped graphene	324	0.1 A g ⁻¹	6 M KOH
²⁶	Nitrogen doped RGO	340	0.5 A g ⁻¹	6 M KOH
²⁷	N-graphene from silk cocoon	348	5 mV s ⁻¹	1 M H ₂ SO ₄
²⁸	B doped graphene	281	1 A g ⁻¹	2 M H ₂ SO ₄
²⁹	S doped RGO	343	0.2 A g ⁻¹	2 M KOH
³⁰	S-doped RGO aerogels	445.6	5 mV s ⁻¹	1 M H ₂ SO ₄
³¹	N-doped RGO aerogel	350	1 A g ⁻¹	1 M H ₂ SO ₄

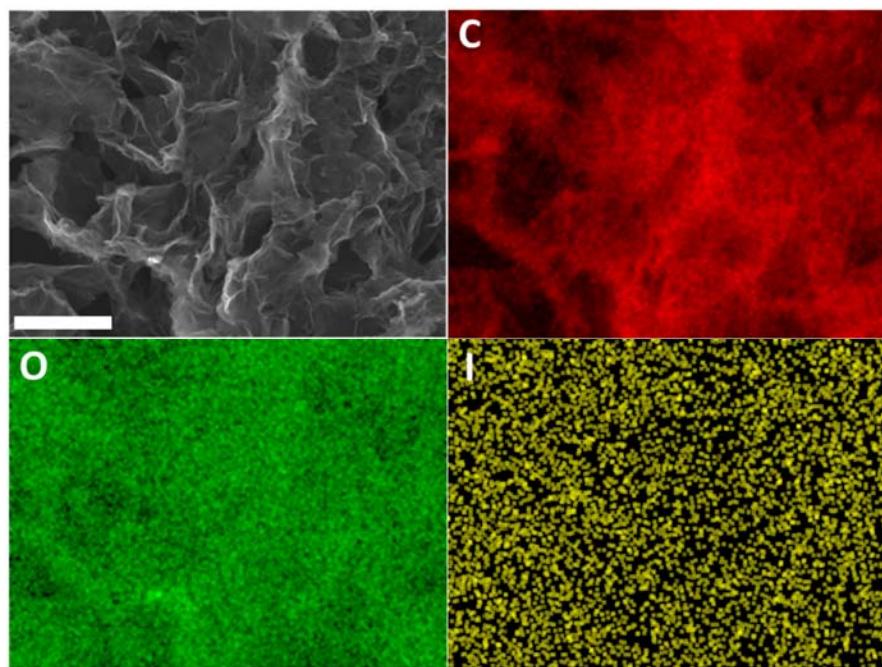


Fig S16. SEM image and corresponding EDX elemental mappings of the HI-RGO/CDs after 10,000 GCD cycles at 10 A g^{-1} . The scale bar is $2.5 \mu\text{m}$.

Table S2. R_{ct} values, Warburg prefactor and diffusion coefficient of H^+ (D_{H^+}) of HI-RGO and HI-RGO/CD electrodes.

	HI-RGO	HI-RGO/CDs
$R_{ct} (\Omega)$	7.9	2.3
$\sigma_w (\Omega \text{ s}^{-1/2})$	269.9	103.7
$D_{\text{H}^+} (\times 10^{-18} \text{ cm}^2 \text{ s}^{-1})$	12.6	85.5

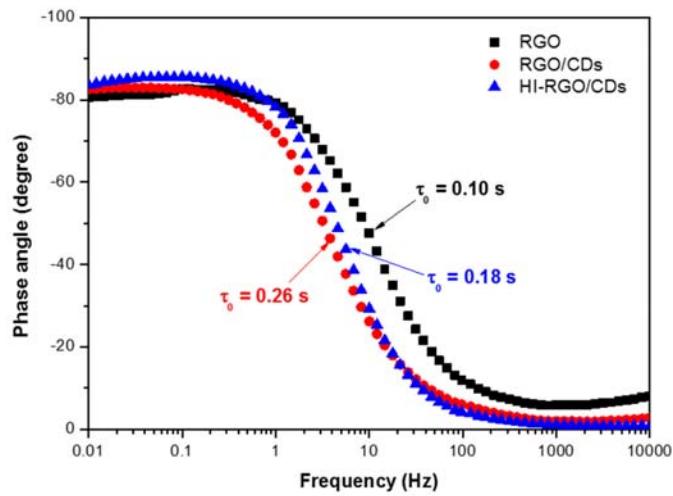


Fig S17. Bode plots of phase angle versus frequency.

Table S3. Total specific capacitance C_{sp} , electrical double layer capacitance (EDLC) and pseudo-capacitance (PC) of electrodes at scan rates, unit $F g^{-1}$.

Scan rate, $mV s^{-1}$	RGO			RGO/CDs			HI-RGO/CDs		
	C_{sp}	EDLC	PC	C_{sp}	EDLC	PC	C_{sp}	EDLC	PC
2	139.3	84.9	54.5	248.4	193.0	55.4	431.9	337.5	94.4
5	114.5	80.1	34.4	234.7	199.6	35.1	409.3	349.5	59.8
10	107.8	83.5	24.3	225.2	200.5	24.7	393.4	351.2	42.2
20	101.2	84.0	17.2	216.9	199.4	17.5	378.9	349.1	29.8
50	95.2	84.3	10.9	206.4	195.3	11.1	360.8	342.0	18.8
100	90.9	83.2	7.7	199.5	191.7	7.8	348.4	335.0	13.4
200	84.3	78.8	5.5	192.7	187.2	5.5	335.5	326.1	9.4
500	77.8	74.3	3.5	182.8	179.3	3.5	315.5	309.5	6.0
1000	70.5	68.1	2.4	173.8	171.3	2.5	295.3	291.1	4.2

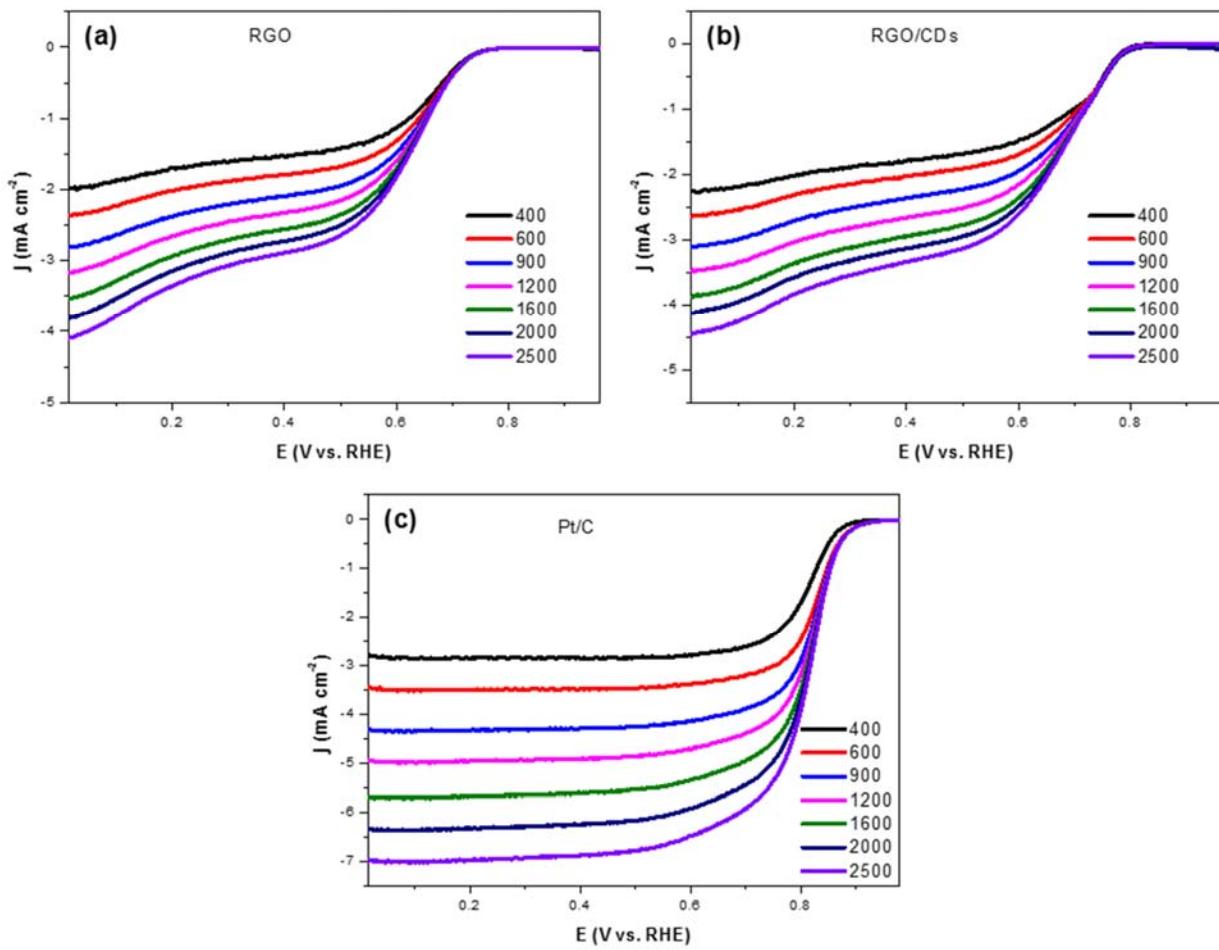


Fig S18. LSV curves of (a) RGO, (b) RGO/CDs and (c) Pt/C at various rotation frequencies in O_2 -saturated 0.1 M KOH.

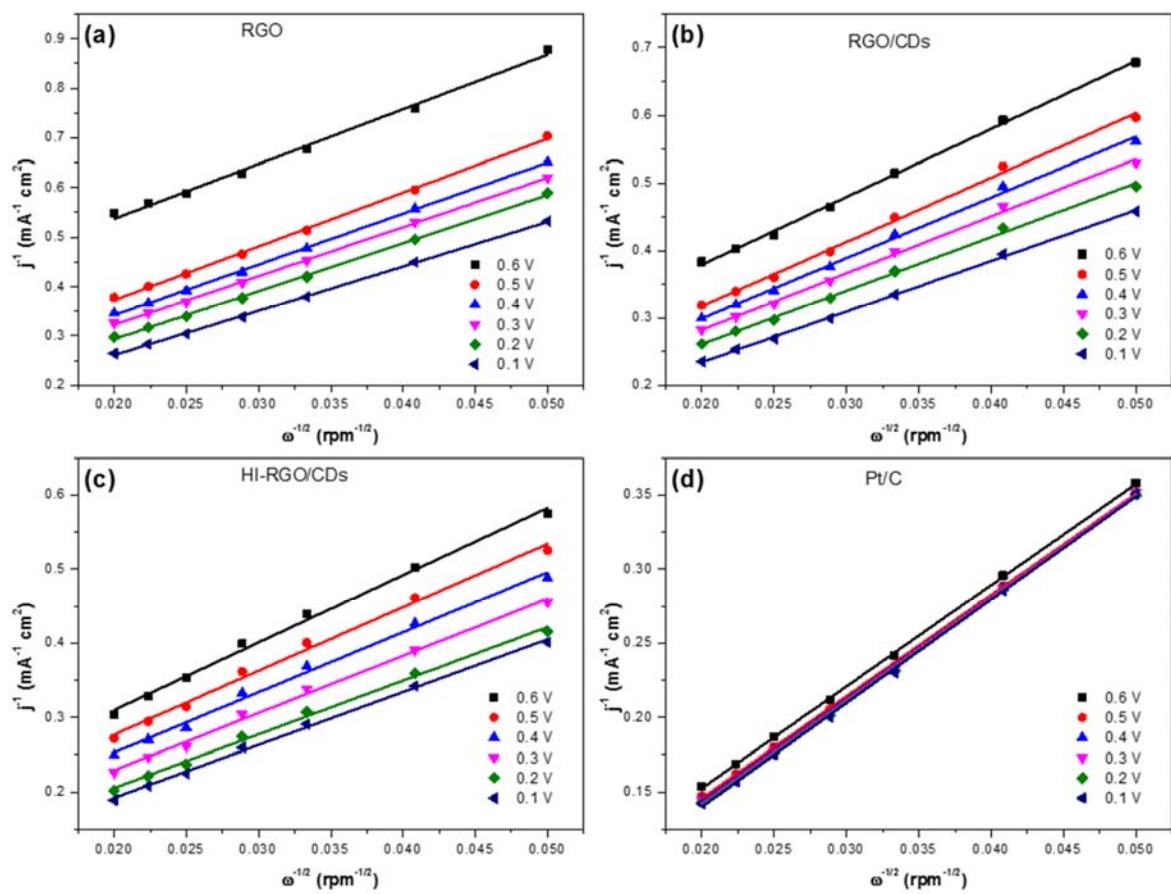


Fig S19. Koutecky–Levich plots of (a) RGO, (b) RGO/CDs, (c) HI-RGO/CDs and (d) Pt/C at several potentials in O₂-saturated 0.1 M KOH.

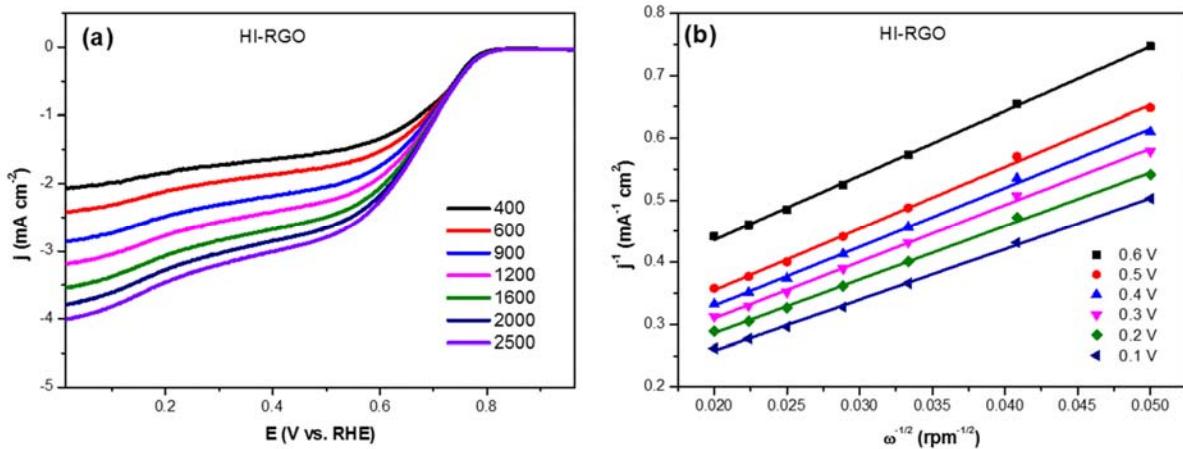


Fig S20. (a) LSV curves of HI-RGO at various rotation frequencies in O₂-saturated 0.1 M KOH. (b) Koutecky–Levich plots HI-RGO at several potentials in O₂-saturated 0.1 M KOH.

Table S4. Comparison of metal-free carbon based ORR electrocatalysts reported in the literature.

References	Catalysts	Onset potential (V) vs. RHE	j _L (mA cm ⁻²)	j _k (mA cm ⁻²)	Electron transfer number, n
This work	HI-RGO/CDs	0.93	4.62	19.8	3.1-4.0
³²	Cl-graphene nanoplatelet	0.804	0.18 mA		3.5 (-0.8 V)
³²	Br-graphene nanoplatelet	~ 0.814	0.28 mA		3.8 (-0.8 V)
³²	I-graphene nanoplatelet	0.824	0.4 mA		3.9 (-0.8 V)
³³	I-graphene	0.884	7.2	9.21	3.86
³⁴	N,I-codoped graphene	0.884		11.76	3.93
³⁵	B-doped graphene	0.914	~0.54 mA		3.5
³⁶	Plasma-treated graphene	0.912			3.85
³⁶	Graphene	0.806			2.31
³⁷	N-graphene	0.826	2.0		1.7-2.0
³⁷	N-CNT	0.837	2.1		1.9-2.3
³⁷	N-graphene/N-CNT	0.869	3.2		3.3-3.7
³⁸	N-graphene	0.764	0.8		3.6-4
³⁹	N-graphene	0.924	~5.1		3.3-4
⁴⁰	N-GQDs	0.969			3.9
⁴¹	N-graphene/CNT	0.91	~5.4		3.78-3.93
⁴²	N-hollow mesoporous graphene analogous spheres	0.14			3.9
⁴³	N,P-carbon	0.9	~5.0	12.9	3.86
⁴⁴	N, P-mesoporous nanocarbon	0.94	~4.2	~26	3.85
⁴⁵	N,P-CNTs/ graphene nanospheres	0.94		5.9	3.95
⁴⁶	R2CPC	0.778			2.5
⁴⁶	R4CPC	0.738			3.7
³	N,S-graphene/CDs	0.84			3.5-3.75
⁴⁷	N-doped carbon aerogels	0.844			3-3.7
⁴⁸	Soy protein- derived porous carbon aerogels	0.904			3.3-3.7
⁴⁹	N,S-carbon aerogels	0.834			2.7-3.7
⁵⁰	N-porous carbon	0.85	2.67	2.42	3.5-3.9
⁵¹	N-doped carbon	1.224	4.24		3.4
⁵²	Cellulose-derived carbon	~ 0.92	3.3	6.9	3.6-3.9
⁵³	Corn starch-derived carbon nanosheets	0.934	4.5	8.1	3.5
⁵⁴	N-carbon fiber aerogel	1.01	4.7		3.47-3.9

⁵⁵	Chitosan-derived N-carbon	0.934	4.9	37.04	3.42-3.67
⁵⁶	N,S-carbon nanoplatelets	0.97	7.06		3.8
⁵⁷	Water hyacinth derived porous carbon	0.98	4.5	1.04	3.51-3.82
⁵⁸	Bamboo fungus derived carbon	0.089 ^a	3.55		3.6
⁵⁹	Pulsatilla chinensis (bunge) Regel-derived carbon	0.944	4.36		3.46-3.6
⁶⁰	Human urine-derived porous carbon	0.934	3.5		3.7
⁶¹	N,S-codoped 3D porous graphene	0.904	5.34		3.52-3.83

^a The potential is given with respect to Hg/HgO reference electrode.

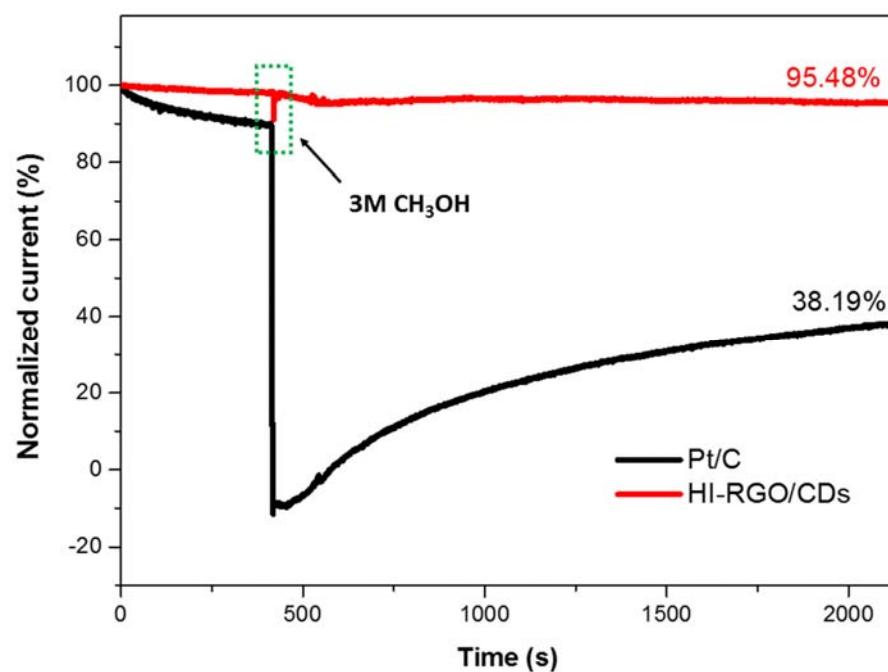


Fig S21. i-t chronoamperometric reponses of HI-RGO/CDs and commercial Pt/C before and after the addition of 3.0 M methanol to O₂-saturated 0.1 M KOH electrolytes.

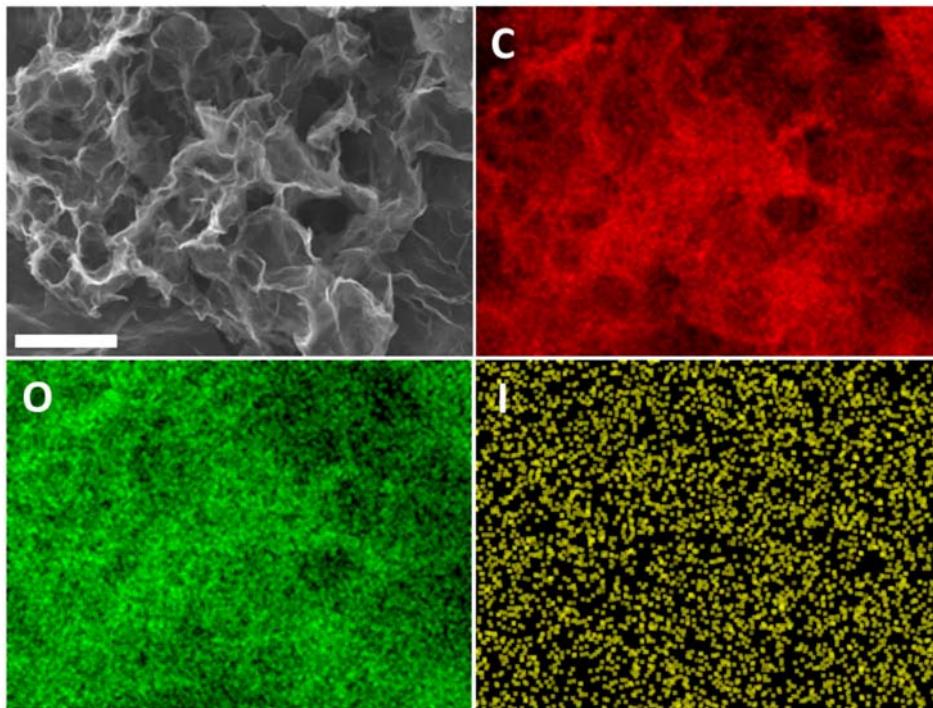


Fig S22. SEM image and corresponding EDX elemental mappings of the HI-RGO/CDs after 22 h ORR stability test. The scale bar is 2.5 μm .

ECSA of materials

The electrochemically active surface areas (ECSA) of the samples were determined from their double layer capacitance (C_{dl}). CV scans were carried out in a non-Faradaic region between -0.1 and 0 V (vs. Ag/AgCl) at various scan rates from 5 to 100 mV s^{-1} in 0.1 M KOH. C_{dl} was calculated from following formula:

$$C_{dl} = \frac{1}{2Vv} \int_{V_-}^{V_+} i(V)dV \quad (1)$$

ECSA was then normalized by specific capacitance of corresponding materials (C_s):

$$\text{ECSA} = \frac{C_{dl}}{C_s} \quad (2)$$

Since a commonly used C_s value for carbon is 20 mF cm^{-2} ⁶², we calculated ECSA values of the catalysts and the results are depicted in Fig S21e.

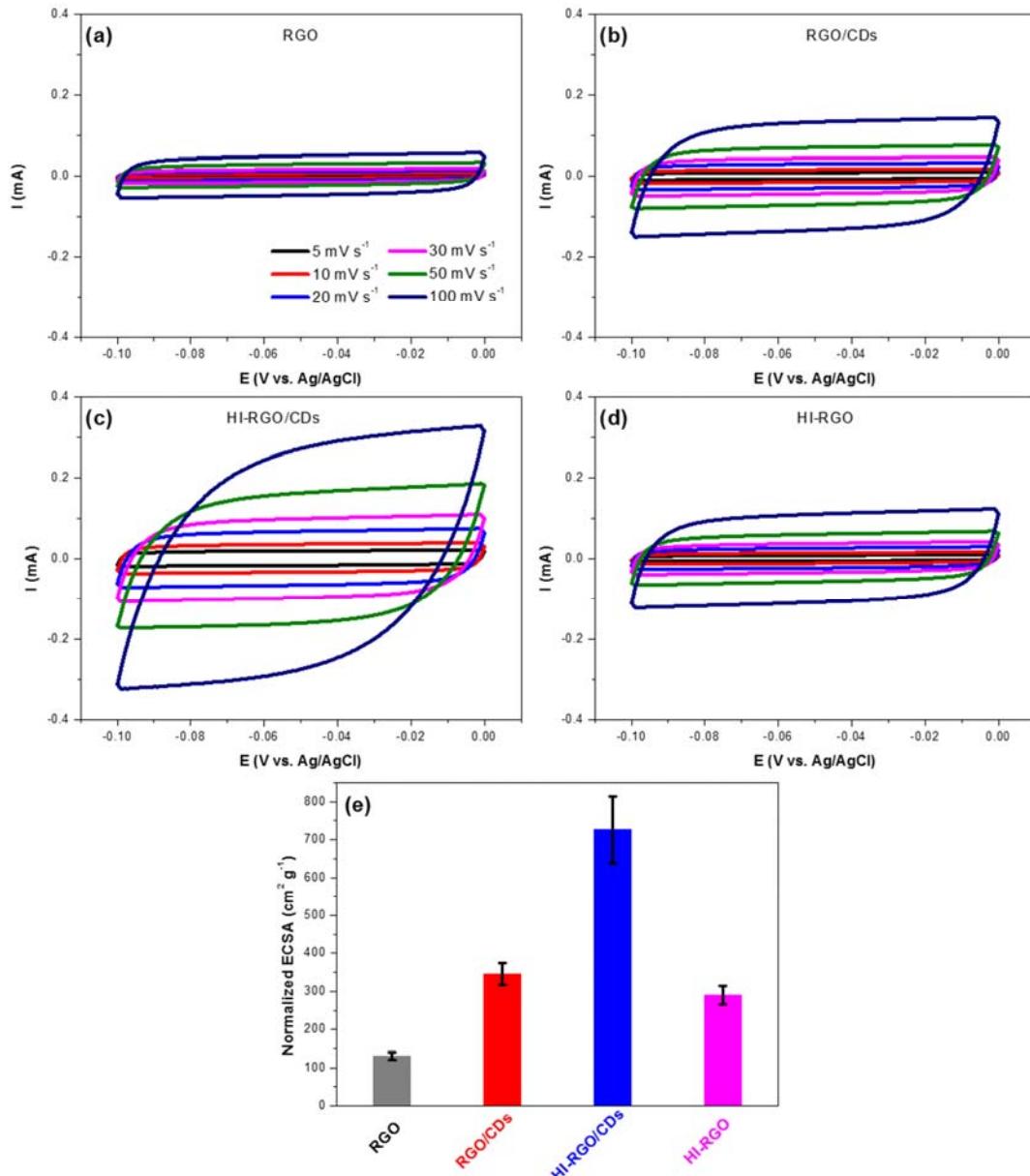


Fig S23. CV scan curves of (a) RGO, (b) RGO/CDs, (c) HI-RGO/CDs and (d) HI-RGO at variable scan rates from 5 to 100 mV s⁻¹ in 0.1 M KOH; (e) corresponding ECSA of four electrodes.

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